

Title (en)

METHOD FOR PRODUCING ELECTRICALLY SEMICONDUCTIVE OR CONDUCTIVE LAYERS WITH IMPROVED CONDUCTIVITY

Title (de)

VERFAHREN ZUR HERSTELLUNG ELEKTRISCH HALBLEITENDER ODER LEITENDER SCHICHTEN MIT VERBESSERTER LEITFÄHIGKEIT

Title (fr)

PROCÉDÉ DE FABRICATION DE COUCHES ÉLECTRIQUEMENT SEMI-CONDUCTRICES OU CONDUCTRICES PRÉSENTANT UNE CONDUCTIVITÉ AMÉLIORÉE

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Application

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Abstract (en)

[origin: WO2013110434A1] The invention relates to a method for producing electrically semiconductive or conductive metal oxide layers with improved conductivity that are particularly suitable for the production of flexible thin-film transistors, to metal oxide layers produced therewith, and to the use thereof for producing electronic components.

IPC 8 full level

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CPC (source: CN EP KR US)

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Citation (search report)

See references of WO 2013110434A1

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